

Nanoscale Structural and Emission Properties within “Russian Doll”-Type InGaN/AlGaIn Quantum Wells

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Due to the increasing desire for nanoscale optoelectronic devices with green light emission capability and high efficiency, ternary III-N-based nanorods are extensively studied. Many efforts have been taken on the planar device configuration, which lead to unavoids defects and strains. With selective-area molecular-beam epitaxy, new “Russian Doll”-type InGaIn/AlGaIn quantum wells (QWs) have been developed, which could largely alleviate this issue. This work combines multiple nanoscale characterization methods and k-p theory calculations so that the crystalline structure, chemical compositions, strain effects, and light emission properties can be quantitatively correlated and understood. The 3D structure and atomic composition of these QWs are retrieved with transmission electron microscopy and atom probe tomography while their green light emission has been demonstrated with room-temperature cathodoluminescence experiments. k-p theory calculations, with the consideration of strain effects, are used to derive the light emission characteristics that are compared with the local measurements. Thus, the structural properties of the newly designed nanorods are quantitatively characterized and the relationship with their outstanding optical properties is described. This combined approach provides an innovative way for analyzing nano-optical-devices and new strategies for the structure design of light-emitting diodes.


1. Introduction

Driven by the increasing needs for smaller footprint, higher light emission efficiency, and full-spectrum RGB light emission, semiconductor devices with desired properties are being widely explored.^[1] Ternary III-N based nanorod (NR) heterostructures are known for their excellent light emitting stability and tunable color emission ability.^[2–6] The light emission in the green light range is particularly crucial for visible light communication, high-density optical information storage, full-color LED designs and so on.^[7,8] Using In atoms to (partially) replace Ga atoms in the GaN lattice, the bandgap of (In)GaIn decreases from 3.30 to 0.65 eV,^[9,10] which could cover the whole region of visible light.^[6] When including Al atoms, the bandgap of (Al)GaIn can increase from 3.30 to 6.06 eV.^[11] Therefore, the elemental composition plays a significant role in modulating the light emission wavelengths of the nanorods. Furthermore, both axial and

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radial ternary III-N heterostructure configurations have been proposed.^[12–19] The planar configuration of the ternary III-N heterostructures has been extensively studied for its simplicity, but it is generally limited by the difficulty in controlling defect density and strain effects.^[12–14] The relatively large spontaneous polarization and piezoelectric field could adversely influence the performance of the devices. The radial heterostructures could largely reduce polarization fields. However, there are several obstacles hindering the development of radial devices: (1) *m*-plane substrates are usually expensive, increasing the costs of the devices; (2) The epitaxial growth of the heterostructures on the nonpolar planes will lead to poor crystal quality;^[15] (3) They are restricted by achieving uniform current spreading, limiting the applications to single radial devices.^[16–18] Therefore, it is important to explore novel structure design strategies for the ternary III-N heterostructures. Growing InGaN on a semipolar surface has been found to be an efficient way to increase the In content and reduce the defects,^[20,21] while its nanoscale structure-property relationship remains largely unexplored. The spontaneous polarization direction of (In/Al)GaN is along [0001] in the wurtzite structure, the larger the slope of the facet the smaller the component of the polarization field perpendicular to the facet.^[22–25] Facets with larger slope display decreased quantum-confined Stark effect and thus could exhibit higher light emitting efficiency.^[21,26,27]

Selected-area molecular-beam epitaxy (MBE) growth has been demonstrated to be a controllable way of growing ternary

III-N based nanorods in a bottom-up approach, which could dramatically reduce the number of defects (especially dislocations and/or stacking faults).^[26,28,29] The nucleation of the nanowires from adatoms can be limited only to the exposed surface on the substrate leading to uniform morphology of the nanorods. Here, the GaN nanorods with sequential layers of “hollow hexagonal pyramid”-shaped InGaN/AlGaIn quantum wells (QWs) (InGaN/AlGaIn@GaN NR) were synthesized by selected-area MBE.^[26] The corresponding atomic structures and the 3D morphology and composition were further characterized with scanning transmission electron microscopy (STEM) and atom probe tomography (APT). Combined with the cathodoluminescence (CL) spectroscopy measurement of the InGaN/AlGaIn@GaN NR, the corresponding optical properties were successfully correlated with their composition and strain. Our results and combined strategy provide a new understanding of the light emission wavelengths based on the crystal structure and composition, and will contribute to the design and performance improvement of III-N-based LED.

2. Results and Discussions

Figure 1a presents a top-view scanning electron microscopy (SEM) image of the vertically grown InGaN/AlGaIn@GaN NRs which grow along the *c*-axis of GaN and possess a hexagonal shape with six {10 $\bar{1}$ 0} side facets. The InGaN/AlGaIn@GaN NR array exhibited a high degree of uniformity with a diameter of ≈ 200 nm. **Figure 1b** shows a high-angle annular dark-field scanning transmission electron microscopy (HAADF-STEM) image of the cross-sectional sample extracted and thinned following Focused Ion Beam (FIB) milling (from the red framed region in **Figure 1a** and viewed along the [2 $\bar{1}$ 10] zone axis. From this projection, a “boomerang”-shaped QW region can be clearly observed within the GaN NR and a schematic illustration of the InGaN/AlGaIn@GaN NR geometry can be found in **Figure S1**, Supporting Information. A high-resolution HAADF-STEM image of the yellow framed region in **Figure 1b** is shown in **Figure 1c**, where eight pairs of alternating InGaN/AlGaIn layers can be clearly observed. For extremely thin III-Nitrides quantum wells and quantum disks, the quantum confinement effect is strong when the thickness is 1–3 atomic monolayers.^[30–35] In our system, the thickness of each InGaN or AlGaIn layer is measured to be 9 atomic monolayers or above, thick enough to neglect the spatial quantum confinement. Since the contrast of the HAADF-STEM images is highly dependent on the effective atomic number (*Z*), and elements with a higher *Z* appear brighter in the resulting image,^[36] InGaN layers are brighter than the neighboring AlGaIn layers in the GaN NR.

It should be mentioned that the interfaces of InGaN/AlGaIn QWs evolve from the (0 $\bar{1}$ 12) plane into the (0 $\bar{1}$ 11) plane as shown in **Figure 1c**, suggesting that the (0 $\bar{1}$ 12) plane is more energetically stable and behaves as the growth front during the growth of GaN, while the (0 $\bar{1}$ 11) plane is the most energetically favorable plane for the InGaN/AlGaIn growth. Due to different chemical potential for different facets, GaN shows growth-rate anisotropy.^[27,37] A closer examination of the QWs revealed that the growth planes of InGaN/AlGaIn evolved from (0 $\bar{1}$ 12) to (0 $\bar{1}$ 11) plane within four pairs of QWs from bottom to top.

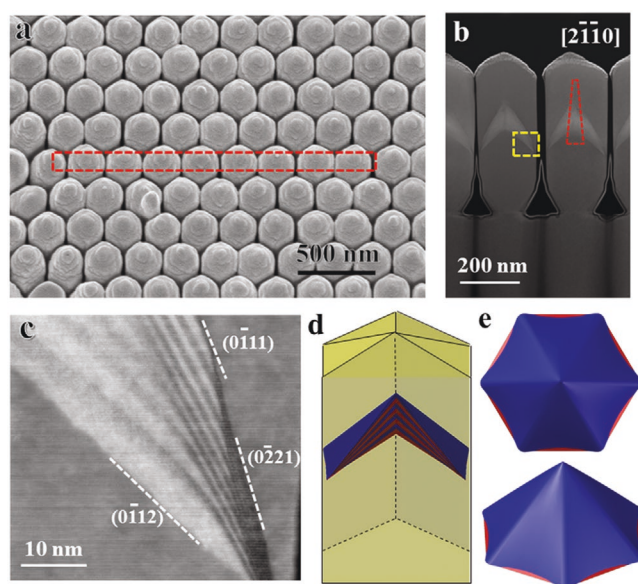


Figure 1. Electron microscopy characterization and schematic illustration of the InGaN/AlGaIn QWs@GaN NR. a) SEM image showing the top view of the NR. The red dashed rectangle indicate the FIB fabrication region. b) Low magnification HAADF-STEM image of the FIB-fabricated cross-sectional sample viewed along the [2 $\bar{1}$ 10] zone axis. The area in the framed red triangle shows the position of the sample extracted for the atom probe tomography experiments. c) High resolution HAADF-STEM image of the yellow framed region in (b). d) Schematic illustration of the InGaN/AlGaIn QWs@GaN NR configuration. The GaN, InGaIn, and AlGaIn are shown in yellow, red and blue colors, respectively. Only four pairs of InGaIn/AlGaIn layers have been illustrated for simplicity. e) The top-view and side-view of one pair of the InGaIn/AlGaIn QWs.

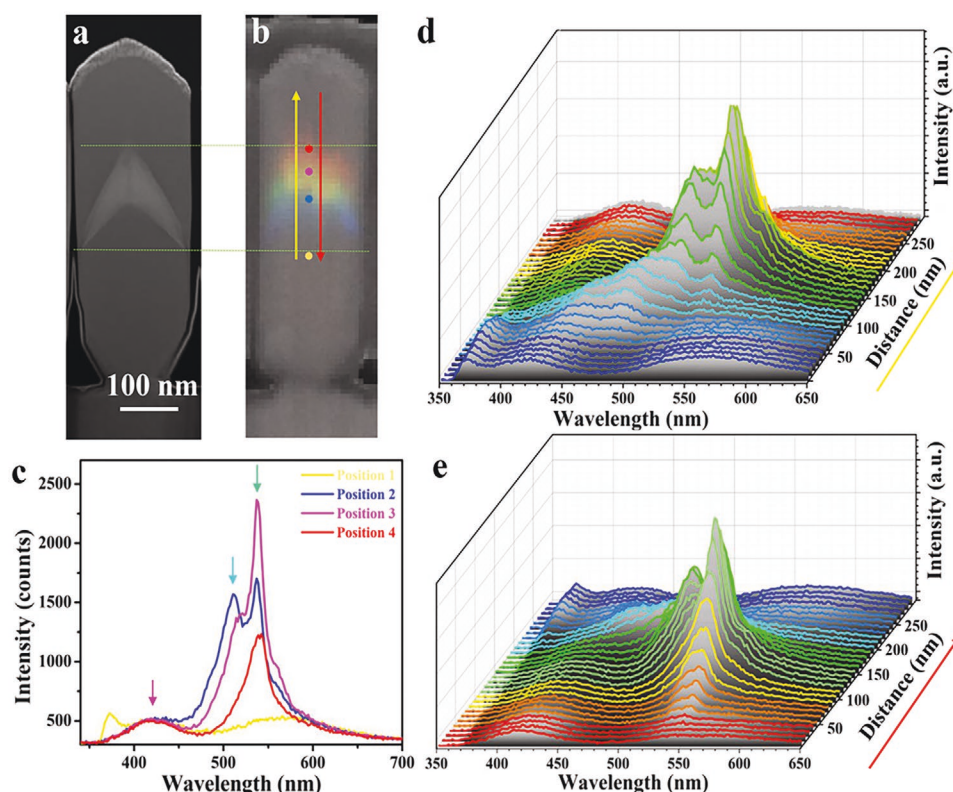


Figure 2. Cathodoluminescence (CL) analyses for InGaN/AlGaIn QWs. a) HAADF image for the QWs. b) Spatially resolved CL mapping for the QWs overlaid on a SEM image of the area scanned. The horizontal green dashed lines are used as the reference position between the CL mapping and HAADF image. c) The CL spectra extracted from the dotted positions in (b). Spectrum for position 1 corresponding to the yellow dot position shown in (b) and located below the bottom of the stack while Spectrum for position 4 corresponds to the top of the stack and the red dot in (b). d) The line scan CL results along the yellow arrow area in (b). e) The line scan CL results along the red arrow area in (b).

A schematic 3D illustration of the InGaN/AlGaIn QWs@GaN NR is shown in Figure 1d. In each InGaN and AlGaIn layer, the growth planes converged to the same points at the bottom corners (Figure 1c and Figure S2, Supporting Information), due to the fact the lateral growth is slower than axial growth. Compared with the planar configuration illustrated in Figure S2, Supporting Information, the free carriers within InGaIn functional layers can be better screened by the AlGaIn layers all around the InGaIn structures in this “Russian Doll” hollow hexagonal pyramid shape (the sealing AlGaIn structures are clearly visible in Figure 1c). The recombination of carriers with surface defects can be effectively avoided, which has the potential to boost the light-emission efficiency.

Then, CL spectroscopy was performed to investigate the specific local optical properties of the synthesized InGaN/AlGaIn QWs@GaN NR leading to direct information on the local optical response of such NRs as demonstrated in Figure 2.^[38] Figure 2a shows the HAADF-STEM image of the cross sectional view of the FIB sample, which was thinned down to one-nanorod thick (about 200 nm) at very low ion beam voltage (5 keV) in order to study the light emission performance of the whole InGaN/AlGaIn QWs stack within the NR. The spatially resolved CL emission wavelengths mapping for the InGaN/AlGaIn QWs, overlaid on the corresponding SEM image, is shown in Figure 2b. The distribution of light follows the QWs shape and shows a range of colors. According to the CL spectra

and color maps, it is observed that the light emission ranges from 350 to 600 nm and the emission originates from different regions of the InGaN/AlGaIn QWs. The CL spectra of the emitted light within the visible range extracted from four different positions (highlighted in Figure 2b with separate dots of different colors) are plotted in Figure 2c. More spectra extracted from different areas can be found in the Supporting Information document. Since AlGaIn possesses a larger bandgap than InGaIn, the light emission in the visible range mainly comes from the InGaIn layers. The dot marked as Position 1 (the yellow dot and spectrum) at the bottom of the stack corresponding to the pure GaN region and the peak near 372 nm is a characteristic CL peak for bulk GaN.^[39,40] Figure 2d,e show the CL line-scan results along the yellow and red arrows directions indicated in Figure 2b, respectively. According to our CL measurement, it is found that the InGaN/AlGaIn QWs mainly emit in the range of 510–538 nm (indicated by the green arrows in Figure 2c, corresponding to green light).

Since the concentration of In in ternary III-N compounds can most effectively influence the band gap which directly determines emission properties, investigation of the 3D composition distribution of the “boomerang”-shaped InGaN/AlGaIn QWs is an absolute necessity for the understanding of its light emitting performance. However, characterization methods such as electron energy loss spectroscopy (EELS) or energy dispersive X-ray spectroscopy, due to the integration of signals from projections,

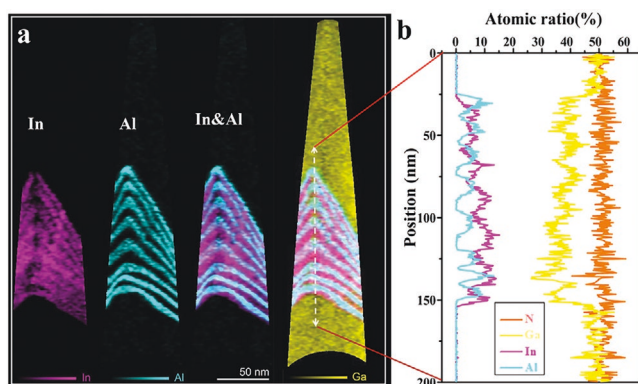


Figure 3. Concentration maps of In, Al, Ga taken from a 5 nm thick subsection of the nanorod APT data. a) The concentration of In, Al, In&Al, and Ga (from left to right). The color bars represent the relative amounts of each element. b) The atomic ratio for each element across the QWs.

cannot directly extract 3D information about the composition distribution of the InGaN/AlGaN QWs with such a complex geometry. As an analytical method, APT has been proven to be an effective tool to provide 3D information of semiconductor materials with complex morphology, structure and composition distributions.^[41–43] Therefore, the APT technique is applied here to directly reveal the 3D composition distribution of the InGaN/AlGaN QWs. As shown in **Figure 3a**, a needle-like InGaN/AlGaN QWs@GaN sample fabricated from the red framed region in **Figure 1b** was used for the APT measurement. The atomic composition maps for In, Al, In&Al, and In&Al&Ga are presented in **Figure 3a**, from which we can find that the Al rich layers (AlGaN) are well separated and sharp while the In layers (InGaN) are relatively smeared out. This might be caused by the relatively higher mobility of In than Al during the synthesis process.^[44] The atomic ratios of the Al, In, Ga, and N elements are presented in **Figure 3b**, from which eight atomic ratio peaks of In and Al can be observed, corresponding to the eight pairs of InGaN/AlGaN QWs. As expected, the atomic ratio of N was measured to be 50% both in the GaN, and across the InGaN/AlGaN QWs (**Figure 3b**).

Accompanied with detailed analyses of the composition distribution, the detailed 3D morphology of InGaN/AlGaN QWs can also be demonstrated in APT. As shown in **Figures S4** and **S5**, Supporting Information, the top AlGaN facet is flat, while the bottom facet exhibits a curved morphology. The curved facet evolves between the (0 $\bar{1}$ 11) plane and the (0 $\bar{1}$ 12) plane, because (0 $\bar{1}$ 11) and (0 $\bar{1}$ 12) are the most energetically favorable planes for the growth of AlGaN and GaN respectively.^[45,46] As shown in **Figure 1c**, it is important to mention that the intensity of the bottom four AlGaN layers is relatively weaker compared with the intensity of the top four AlGaN layers and that the apparent width of the layer is also larger for the bottom InGaN dots than the top ones, all factors which can be explained by the curved nature of the bottom AlGaN layers. Given the complex nature of this heterostructure, it is clear that the combination of APT technique with the information from TEM are the only combined approaches that can reveal this slightly curved nature of the quantum layers and the crystallographic nanosized structure within the heterostructures.

In order to provide a better understanding on the light emission behavior of the InGaN/AlGaN QWs@GaN NRs, calculations based on *k*·*p* theory in which important materials parameters were obtained from DFT results, were further utilized to elucidate the band structure modulation due to In incorporation and the strain effects. First of all, without considering strain effects, the evolution of light emission of GaN with different concentrations of In and Al is shown in **Figure S7a**, Supporting Information. The light emission can be tuned from the ultraviolet to visible light with increasing In doping levels. Equally important, the results of our calculation show that the InGaN could achieve full-visible-light emission with different In concentrations. According to the light emission spectra (**Figure 2**), three compounds corresponding to the three CL peaks (marked by arrows) should appear within InGaN layers. Considering the fact that atomic concentration maps of each element acquired from APT (**Figure 3b**) cannot directly reflect the CL light emission property and the light emission spectra (**Figure 2**), we used a linear combination method to inversely retrieve the relative fractions for each InGaN compound in the NR. The relative fractions of three InGaN compounds in the nanorod are quantitatively obtained and plotted in **Figure S7b**, Supporting Information. With respect to AlGaN in this NR, this compound will not contribute to the visible-light emission. Alternatively, AlGaN acts as the confinement layer for the recombination of the excitons as discussed above.

It should be mentioned that, as displayed in **Figure 1c**, InGaN and AlGaN layers are grown alternating. InGaN layers will inevitably experience biaxial stress induced by the lattice mismatch, typically, (0 $\bar{1}$ 12), (0 $\bar{1}$ 11), and (0 $\bar{2}$ 21) planes as depicted in **Figure 1c**. The different factors will have different influence on the properties.^[47,48] Through the use of the *k*·*p* perturbation approach^[49–52] and deformation potential theory^[53] (See details in the Supporting Information), we calculated the biaxial strain effect on the light emission spectra of In_{*x*}Ga_{1–*x*}N. Since the strain components vary depending on which crystal plane the InGaN was grown, three light emission wavelength evolution graphs along with different In concentrations of In_{*x*}Ga_{1–*x*}N grown on (0 $\bar{2}$ 21), (0 $\bar{1}$ 11), and (0 $\bar{1}$ 12) planes are presented in **Figure 4a** and **Figure S8**, Supporting Information. The detailed strain components and bandgap changes brought by these biaxial stresses for different In_{*x*}Ga_{1–*x*}N compounds with various In content *x* are summarized in **Table S1**, Supporting Information. Considering the fact that CL spectra were acquired from the whole QWs (the sample thickness for CL tests was about 200 nm), the strain effects from these three energy favorable planes are considered. Then, the relative fraction of the three InGaN compounds over different growth planes, that is, (0 $\bar{2}$ 21), (0 $\bar{1}$ 11), and (0 $\bar{1}$ 12), are quantitatively obtained and plotted in **Figure 4b**. For InGaN, there are three different compounds existing in the nanorod. They are In_{0.10}Ga_{0.90}N, In_{0.27}Ga_{0.73}N, and In_{0.31}Ga_{0.69}N, whose bandgap are 2.97, 2.43, and 2.31 eV, corresponding to light emission wavelength of 418, 510, and 538 nm, respectively. It should be mentioned that In_{0.27}Ga_{0.73}N and In_{0.31}Ga_{0.69}N will contribute to green light emission, and they are the main compositions of the nanorod. Comparing the results with (**Figure 4b**) and without (**Figure S7b**, Supporting Information) strain effects, we find the strain will modify the effective components. Taking the

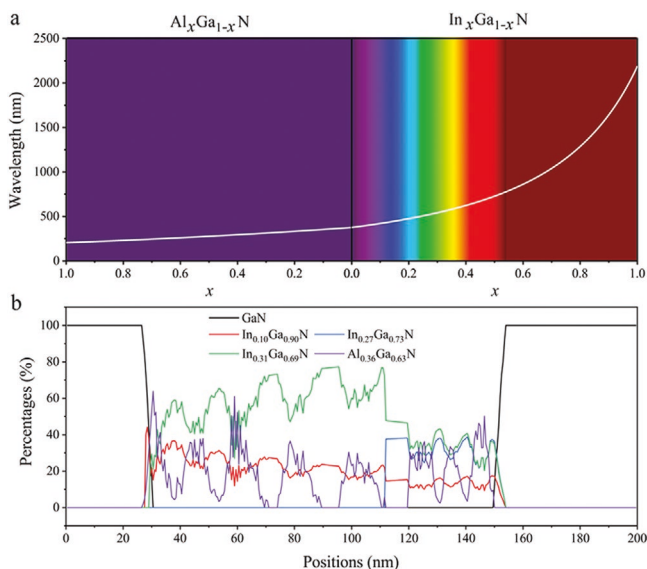


Figure 4. Calculated light emission and nanorod compositions analyses. a) Light emission wavelength evolution in $\text{Al}_x\text{Ga}_{1-x}\text{N}$ and $\text{In}_x\text{Ga}_{1-x}\text{N}$ where biaxial stress induced by the lattice mismatch between $\text{InGaN}(0021)$ and $\text{AlGaN}(0021)$ are taken into consideration. Infrared light is marked as dark red (rightmost), and ultraviolet light is marked as dark purple (leftmost). The white curve depicts the wavelength of light emission spectra peak evolution along with different concentrations. b) The percentage distributions of different compounds in the nanorod along the $[0001]$ pole. The chemical formula of InGaNs are obtained from the averaged strain components. X-axis the same as the Y-axis in Figure 3b.

broadening of the light emission spectrum peaks into consideration, blue-green-yellow emission could be achieved in these NRs. The broadening of the peak is mainly related to the broadening of the valence band maximum and conduction band minimum in $\text{In}_x\text{Ga}_{1-x}\text{N}$, and the compositional fluctuation of the elements across the QWs.

Additionally, all the interfacial planes in the featured region of the NR are semipolar ones in the III-Nitrides (Figure 1c). Compared with the polar c -plane which has an estimated polarization field strength 0.042 C m^{-2} , the polarization fields are estimated to be in the range of $0.000\text{--}0.004 \text{ C m}^{-2}$ in the semipolar $\text{InGaN}/\text{AlGaN}$ QWs (SQWs), essentially close to zero which is the value for nonpolar QWs. In these conditions the carrier overlap is increased,^[54,55] leading to enhanced performance of light emitting in SQWs. On the other hand, as plotted in Figure S9, Supporting Information, the transition energy change, E_3 (Equation (3) in the Supporting Information for more details), which determines the strain-induced bandgap change of InGaN , is always much smaller in SQWs than that in the nonpolar $\text{InGaN}/\text{AlGaN}$ QWs. This means that, for a given x in $\text{In}_x\text{Ga}_{1-x}\text{N}$, SQWs always have a smaller bandgap, helping with the green-light-emission. With the observed curved nature of AlGaN , the effect on the light emission properties of the nanorods can be estimated based on the above analysis of the strain-induced transition energy changes as well as the influence of polarization fields existing on different III-Nitrides planes. The facets with large slope have small polarization field. Consequently, facets with larger slope exhibit higher light emitting efficiency. Second, facets with small slope will be favorable

for achieving the challenging light emission within the long wavelength region, such as green or even red-light emission, which is due to the smaller transition energy changes. Therefore, our findings provide a useful guidance for the structure design of InGaN based optical device.

3. Conclusions

Using a combination of transmission electron microscopy, atom probe tomography, cathodoluminescence spectroscopy, and $k \cdot p$ theory calculations, we have elucidated the structure and properties relationships of these “Russian Doll”-type $\text{InGaN}/\text{AlGaN}$ QWs. A new 3D design for the quantum heterostructures by selective-area molecular-beam epitaxy method has been demonstrated, achieving green light emission. Their structure, with growth on semi-polar planes, could efficiently reduce the defects and strain effects compared with traditional planar design of ternary III-N heterostructures. More insights have been provided for understanding the behavior of light emission within the quantum wells. This work provides a new route for robust, transferable 3D-nanoscale optical and structural analyses in modern nanoscale materials and devices.

4. Experimental Section

Sample Fabrication: Zeiss NVision 40 (Carl Zeiss, Germany) dual-beam FIB system was used to prepare samples for the TEM, APT, and CL characterization, with the low-voltage ion beam at 5 kV as the final step for reducing/removing the surface damage layers. The schematic diagram of the sample configuration can be found in the Supporting Information. It should be mentioned the thinner lamellae (less than one-nanorod thick) for CL tests clearly behaved differently suggesting that the material and/or carrier behavior was altered.

Characterization: The TEM studies were carried out using a FEI Titan 80/300 TEM equipped with a high-resolution electron energy-loss spectrometer (Gatan Imaging Filter (GIF) model 966) and a state-of-the-art Gatan K2 Summit direct electron detector (K2 IS). The HAADF-STEM images and spectrum images were acquired at 200 kV with a convergence semi-angle of 19 mrad and a GIF collection semi-angle of 20.7 mrad. The dwell time of the EELS mapping was set to 30 ms to increase the mapping area and minimize the beam damage. The SEM images were captured with a ThermoFisher Scientific G4 Plasma FIB equipped with a monochromated Elstar SEM column. The secondary electron image was then collected by using a Through Lens detector (TLD) at 25 pA, 1 kV under immersion mode, with monochromator on.

The APT analyses were performed using a Cameca Instruments LEAP 4000 \times HR operating in laser-pulsing mode ($\lambda = 355 \text{ nm}$) with a pulse energy of 50 fJ and a pulse rate of 100 kHz. A target detection rate of 1% (0.01 ions per pulse) was maintained for evaporation by controlling the DC voltage applied to the sample, which varied between ≈ 3 and 6 kV. The specimen were held at a base temperature of $\approx 38 \text{ K}$. Data reconstruction and analysis was performed using IVAS 3.8.2, with SEM images of the samples and plane-spacing measurements of $(0001)_{\text{GaN}}$ used to spatially-calibrate the reconstruction.

CL spectroscopy was performed using a SPARC CL detection system mounted on a Thermo Fisher Quanta 650 field emission gun Scanning Electron Microscope.^[56] The SPARC system is equipped with a back-illuminated Peltier-cooled CCD camera mounted on a Czerny Turner spectrograph. Hyperspectral CL imaging was performed using a 300 lines per mm ruled diffraction grating, blazed for a wavelength of 500 nm. The CL emitted from the sample is collected using an aluminium parabolic mirror with an acceptance angle of $1.49\pi \text{ sr}$, aligned with respect to the

sample using a motorized stage. Spatial CL imaging was performed at 30 keV and beam current of 45 pA. These beam conditions gave the most stable and high-resolution imaging results, while maintaining an adequate signal-to-noise ratio.

Supporting Information

Supporting Information is available from the Wiley Online Library or from the author.

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Conflict of Interest

Toon Coenen and Sangeetha Hari work for Delmic BV, the company that develops, manufactures and sells the SPARC CL system used in this work.

Author Contributions

S.C. and Z.W. contributed equally to this work. S.C. conceived and designed the experiments under the supervision of G.A.B. S.C., A.P., H.Y., and X.L. conducted the TEM and SEM experiments. Z.W., X.K., and H.G. performed the simulations. B.L. conducted APT experiments. T.C. and S.H. carried out CL measurement. Y.-H.R., R.T.R., and Z.M. designed and grew the samples. S.C., Z.W., and X.K. co-wrote the paper with all the authors contributing to the discussion and preparation of the manuscript.

Keywords

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